

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	4	(plasma with etch\$3 with polysilicon) and (resist or photoresist) and (residue debris) and (HBr with "Cl.sub.2") and (single with HBr)	US-PGPUB; USPAT	OR	ON	2005/08/16 17:30
L2	2	(etch\$3 with polysilicon) and (resist or photoresist) and (polysilicon with (residue debris contamina\$3 remain\$4)) and (HBr with "Cl.sub.2") and (single with gas with HBr)	US-PGPUB; USPAT	OR	ON	2005/08/16 17:32
L3	3074	438/706,710,719,738.ccls.	US-PGPUB; USPAT	OR	ON	2005/08/16 17:32
L4	1	3 and 1 and 2	US-PGPUB; USPAT	OR	ON	2005/08/16 17:32
L5	1	((etch\$3 with polysilicon) and (resist or photoresist) and (polysilicon with (residue debris contamina\$3 remain\$4)) and (HBr with "Cl.sub.2") and (single with gas with HBr)).clm.	US-PGPUB; USPAT	OR	ON	2005/08/16 17:32
L6	4	suzuki-tamito.in.	US-PGPUB; USPAT	OR	ON	2005/08/16 17:33